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The Intercalation Compound 1,4-Benzenediammonium Tetrachlorocadmate(II)

QIANG YE,^a QIN-JING MENG,^a* XIAO-ZENG YOU^a AND XIAO-YING HUANG^b

^aCoordination Chemistry Institute, State Key Laboratory of Coordination Chemistry, Nanjing University, Nanjing 210008, People's Republic of China, and ^bState Key Laboratory of Structure Chemistry, Fuzhou 350002, People's Republic of China

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Abstract

Crystals of 1,4-benzenediammonium tetrachlorocadmate(II), $(C_6H_{10}N_2)$ [CdCl₄], contain two-dimensional anionic sheets in which each CdCl₆ octahedron shares four corners with adjacent octahedra {*i.e. catena*poly[1,4-benzenediammonium dichlorocadmium-di- μ chloro(2-)]}. Layers of organic diammonium cations are intercalated between the metal-halogen sheets.

Comment

Chemists have become increasingly involved in the synthesis and characterization of various low-dimensional solid-state chain or layer compounds because of their unusual physical properties, *e.g.* superconductivity. About twenty years ago many layer perovskites of general formulae $(C_nH_{2n+1}NH_3)_2MCl_4$ and $(NH_3C_nH_{2n}NH_3)MCl_4$ (M = Cd, Cu, Fe, Mn, Pt, Pd) were investigated in view of their interesting thermal and magnetic properties (Arend & Huber, 1978;

©1996 International Union of Crystallography Printed in Great Britain – all rights reserved Needham & Willett, 1984). The structures of these compounds are very similar to those of Langmuir–Blodgett films. In this paper, we report the crystal structure of such a compound, (I).



From Fig. 1 it can be seen that the title compound consists of two basic species: the CdCl₆ polyhedron and the *p*-phenylene cation. In the $CdCl_6$ layers (Fig. 2*a*), each Cd atom occupies the centre of a distorted but exactly centrosymmetric octahedron formed by four symmetry-related and almost coplanar Cl(1) atoms linking adjacent octahedra plus two axial Cl(2) ligands. In the CdCl₆ layers the bridging Cd—Cl(1)—Cd bond angles are $153.61 (4)^{\circ}$; the Cd atoms of the four closest octahedra and their associated bridging Cl⁻ ions form a pseudo-tetragonal arrangement which extends in two dimensions to form the CdCl₄ sheet (Fig. 2b). The axial Cl(2) ligands protrude above and below the sheets. *p*-Phenylene diammonium cations are trapped between two adjacent CdCl₆ layers and lie in the cavities formed by eight CdCl₆ octahedra (four octahedra form the base and four form the top of the cavity). The axial Cl(2) ligands protrude from the CdCl₄ sheets and thereby hinder the diffusion of the *p*-phenylene cations out of the cavities.

As can be seen from Fig. 2(b), in each *p*-phenylenediammonium layer adjacent aromatic rings are almost exactly normal to one another (dihedral angle 88.2°).

The structure of this layer perovskite is stabilized by N—H···Cl hydrogen bonds from both ends of the *p*-phenylenediammonium cations, which hold adjacent CdCl₆ layers together. They are arranged so that one hydrogen bond [N—H···Cl(1) 3.254 (6) Å] involves the corner-sharing Cl(1) atom whereas the other two from each —NH₃ group [N—H···Cl(2) 3.155 (6) and 3.210 (5) Å] are directed towards the axial Cl atoms of the CdCl₆ octahedra.



Fig. 1. The numbering of the atoms of the title compound with 30% probability displacement ellipsoids. H atoms are omitted for clarity.

$(C_6H_{10}N_2)[CdCl_4]$



(a)



Fig. 2. (a) View of unit cell down the b axis. (b) View of unit cell down the c axis. H atoms are omitted for clarity.

Experimental

The compound was prepared by the reaction of stoichiometric amounts of CdCl2.H2O and NH3C6H4NH3 in 2 M HCl solution. Elemental analysis of the C, H, N, Cd and Cl content corresponds to within experimental error with the composition (NH₃C₆H₄NH₃)CdCl₄. The crystal used for X-ray analysis was obtained by slow evaporation of an aqueous solution of (NH₃C₆H₄NH₃)CdCl₄ at room temperature.

Crystal data

 $(C_6H_{10}N_2)[CdCl_4]$ Mo $K\alpha$ radiation $\lambda = 0.71069 \text{ Å}$ $M_r = 364.38$

Monoclinic $P2_1/a$ a = 7.336(1) Å b = 7.401(2) Å c = 10.408 (4) Å $\beta = 93.34(2)^{\circ}$ $V = 564.2(5) \text{ Å}^3$ Z = 2 $D_x = 2.145 \text{ Mg m}^{-3}$

Data collection Enraf-Nonius CAD-4 diffractometer $\theta/2\theta$ scans Absorption correction: ψ scan (North, Phillips & Mathews, 1968) $T_{\min} = 0.32, T_{\max} = 1.00$ 1174 measured reflections 1105 independent reflections

Refinement

Refinement on F R = 0.055wR = 0.064S = 2.45938 reflections 82 parameters H atoms: positions and U_{iso} refined $w = 1/\sigma^2(F)$ $(\Delta/\sigma)_{\rm max} = 0.07$

Cell parameters from 25 reflections $\theta=13.95{-}14.93^\circ$ $\mu = 2.84 \text{ mm}^{-1}$ T = 296 KPlatelet $1.0 \times 1.0 \times 0.25$ mm Light pink

- 938 observed reflections $[I > 3\sigma(I)]$ $R_{\rm int} = 0.057$ $\theta_{\rm max} = 25^{\circ}$ $h = 0 \rightarrow 8$ $k = 0 \rightarrow 8$ $l = -12 \rightarrow 12$ 3 standard reflections frequency: 60 min intensity decay: 3.1%
- $\Delta \rho_{\rm max} = 1.23 \ {\rm e} \ {\rm \AA}^{-3}$ $\Delta \rho_{\rm min} = -1.11 \ {\rm e} \ {\rm \AA}^{-3}$ Extinction correction: secondary (Zachariasen, 1967) Extinction coefficient: 2.449×10^{-4} Atomic scattering factors from International Tables for X-ray Crystallography (1974, Vol. IV)

Table 1. Fractional atomic coordinates and equivalent isotropic displacement parameters (\tilde{A}^2)

$B_{\rm eq} = (8\pi^2/3) \sum_i \sum_j U_{ij} a_i^* a_i^* \mathbf{a}_i \cdot \mathbf{a}_j.$

	x	y	z	B_{eq}
Cd	0	0	0	1.19 (4)
Cl(1)	0.2990(1)	0.2043(1)	0.03668 (9)	1.91 (5)
Cl(2)	-0.0001(1)	-0.0492(2)	0.2395 (1)	2.15 (5)
N	0.0627 (7)	-0.4709(8)	0.2366 (5)	2.2 (2)
C(11)	0.0321 (9)	-0.4891(5)	0.3727 (6)	1.6(2)
C(12)	-0.1021(6)	-0.6036 (6)	0.4105 (4)	2.0(1)
C(13)	0.1333 (6)	-0.3836 (6)	0.4601 (4)	2.3 (2)

Table 2. Selected geometric parameters (Å, °)

0.000		, ,
2.519(1)	NC(11)	1.454 (8)
2.673(1)	C(11)—C(12)	1.373 (7)
1.382 (7)	CdCl(1")	2.679 (1)
1.383 (6)		
3.254 (6)	$Cl(2) \cdot \cdot \cdot N$	3.155 (6)
3.337 (5)	$Cl(2) \cdots N^{v_{ii}}$	3.210 (5)
89.31 (4)	$Cl(2)$ Cd $Cl(1^{u})$	93.13 (5)
153.61 (4)	C(12)—C(11)—C(13)	121.8 (5)
119.4 (5)	C(13)—C(11)—N	118.8 (5)
118.9 (5)	$C(11)-C(13)-C(12^{n})$	119.3 (4)
91.64 (2)		
	2.519 (1) 2.673 (1) 1.382 (7) 1.383 (6) 3.254 (6) 3.337 (5) 89.31 (4) 153.61 (4) 119.4 (5) 118.9 (5) 91.64 (2)	2.519 (1) NC(11) 2.673 (1) C(11)C(12) 1.382 (7) CdCl(1") 1.383 (6) 3.254 (6) Cl(2)···N 3.337 (5) Cl(2)···N ^v " 89.31 (4) Cl(2)CdCl(1") 153.61 (4) C(12)C(11)C(13) 119.4 (5) C(13)C(12)-N 118.9 (5) C(11)C(13)C(12) ^v) 91.64 (2)

Symmetry codes: (i) -x, -y, -z; (ii) $\frac{1}{2}-x$, $y-\frac{1}{2}$, -z; (iii) $x-\frac{1}{2}$, $\frac{1}{2}-y$, z; (iv) -x, -1-y, 1-z; (v) $\frac{1}{2}+x$, $-\frac{1}{2}-y$, z; (v) $\frac{1}{2}-x$, $\frac{1}{2}+y$, -z; (iv) $(vii) x - \frac{1}{2}, -\frac{1}{2} - y, z.$

The structure was solved by Patterson and Fourier methods and refined by full-matrix least-squares methods, with anisotropic displacement parameters for all non-H atoms.

Data collection: Enraf-Nonius (1982) CAD-4 software. Structure solution and refinement: *TEXSAN* (Molecular Structure Corporation, 1988). Molecular graphics: *ORTEP*II (Johnson, 1976) and *PLUTO* (Motherwell, 1974).

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Lists of structure factors, anisotropic displacement parameters, leastsquares-planes data, H-atom coordinates and complete geometry have been deposited with the IUCr (Reference: MU1132). Copies may be obtained through The Managing Editor, International Union of Crystallography, 5 Abbey Square, Chester CH1 2HU, England.

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Adduct of AlMe₃ with Benzo[*f*]quinoline

XI-MENG WANG,^a HONG-SUI SUN,^a SHUANG-XI WANG,^b XIAO-YING HUANG^c AND XIAO-ZENG YOU^a*

^aState Key Laboratory of Coordination Chemistry, Coordination Chemistry Institute, Nanjing University, Centre for Advanced Studies in Science and Technology of Microstructures, Nanjing 210093, People's Republic of China, ^bState Key Laboratory of Coordination Chemistry, Coordination Chemistry Institute, Nanjing University, Nanjing 210093, People's Republic of China, and ^cState Key Laboratory of Structure Chemistry, Fuzhou 350002, People's Republic of China

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Abstract

The reaction of AlMe₃ with benzo[f]quinoline gave the Lewis acid-base adduct Me₃Al-BQ, (BQ = benzo[f]-quinoline) {(benzo[f]quinoline-N)trimethylaluminium,

 $[Al(CH_3)_3(C_{13}H_9N)]\}$, with an Al—N bond length of 2.057 (2) Å. This adduct is much less air and water sensitive than the trialkyl metal. The complex was found to be a discrete 1:1 molecular adduct of trimethyl-aluminium bonded to BQ. The compound contains a tetracoordinate Al atom with distorted tetrahedral geometry.

Comment

The growth of epitaxial layers of Group III-V and Group II-VI compound semiconductors by metalorganic chemical vapour deposition (MOCVD) is being studied extensively and is progressing towards the production phase for e.g. gallium arsenide. The electrical properties of these layers depend critically upon the purity of the precursors (metal alkyls and hydrides) employed in the semiconductor growth. The development of purification techniques for the removal of metal-containing impurities in these precursors to levels < 1 p.p.m. has provided an exciting challenge for the organometallic chemist (Beachley & Coates, 1965: Bradley, Dawes, Frigo, Hursthouse & Smith, 1990). In this paper we report the synthesis, characterization and X-ray structure determination of a novel intermolecularstabilized organoaluminium complex, (I), as a MOCVD precursor.



The structure consists of a discrete 1:1 molecular adduct of trimethylaluminium bonded to BQ. The compound contains tetracoordinate Al atoms within distorted tetrahedra, with the distortion being towards trigonal pyramidal geometry. The base of the pyramid is defined by the three methyl C atoms. The Al atom is almost coplanar with the plane of the coordinated benzo[f]quinoline (Bradford, Bradley, Hursthouse & Motevalli, 1992). The C-Al-N bond angles [103.9 (1)- $105.5(1)^{\circ}$ are consistently ca 4-5° smaller than the tetrahedral angle. The Al-C bond lengths [1.965(4)-1.987 (3) Å] are within the expected range for metalcarbon single bonds. Thus, it is noteworthy that whereas the Al-C and Ga-C [1.972(5)-1.984(6)Å] (Sun, Wang, Huang & You, 1995) bond distances are very similar to each other, the Al-N bond [2.057(2)Å] is significantly shorter than the Ga-N bond [2.152 (3) Å], implying stronger bonding of BQ to AlMe3 than to GaMe₃.